

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

in re application of

Confirmation No. 7670

Tetsuya MATSUTANI

Docket No. 2003_1039A

Serial No. 10/630,681

Group Art Unit 2812

Filed July 31, 2003

Examiner L. Gurley

CONTACT HOLE FORMATION METHOD

RESPONSE

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Pursuant to the requirement contained in the Office Action mailed December 12, 2003, applicant hereby elects invention I, claims 1-10, drawn to a method of making a semiconductor device.

In view of this election, a full examination on the merits of the present application is respectfully requested.

Respectfully submitted,

Tetsuya MATSUTANI

By: coulta

Charles R. Watts

Registration No. 33,142

Attorney for Applicant

CRW/asd Washington, D.C. 20006-1021 Telephone (202) 721-8200 Facsimile (202) 721-8250

January 5, 2004